



ITW/AF

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:	Wang Yueh et al.	§	Art Unit:	1752
Serial No.:	10/762,031	§	Examiner:	John S.Y. Chu
Filed:	January 21, 2004	§	Docket:	ITL.1074US P18216
For:	One Component EUV Photoresist	§	Assignee:	Intel Corporation
		§		
		§		
		§		

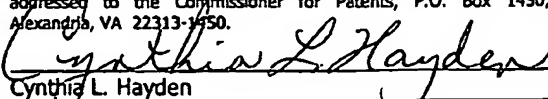
Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REPLY TO FINAL REJECTION

Sir:

In response to the final rejection mailed August 9, 2005, reconsideration is respectfully requested in view of the following remarks.

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Date of Deposit: August 24, 2005
I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Cynthia L. Hayden